

EAST Search History

EAST Search History (Prior Art)

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|---|----------------------------|------------------|---------|---------------------|
| L1 | 2 | "2003197590".pn. | FPRS; EPO; JPO; DERWENT | OR | ON | 2010/05/08 01:15 |
| L2 | 64 | (hydrophobic and hydrophilic) and (substrate wafer semiconductor workpiece) and (rins\$3 wash\$3 clean\$3) and (water near3 (pure\$2 purif\$3 purification demin demineraliz\$5)) | FPRS; EPO; JPO; DERWENT | OR | ON | 2010/05/08 01:22 |
| L3 | 22 | 2 and (surface area region) and ("both" mixed) | FPRS; EPO; JPO; DERWENT | OR | ON | 2010/05/08 01:24 |
| L4 | 61 | 2 and (surface area region) | FPRS; EPO; JPO; DERWENT | OR | ON | 2010/05/08 01:24 |
| S1 | 1 | "20070131256".pn. | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 14:52 |
| S2 | 2 | ("20080173333" "5997653").PN. | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 14:53 |
| S3 | 1 | S1 and (hydrophobic hydrophilic) | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 15:24 |
| S4 | 2 | S2 and (hydrophobic hydrophilic) | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 15:24 |
| S5 | 1 | "20030084925".pn. | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 15:26 |
| S6 | 0 | S2 and S5 | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 15:26 |
| S7 | 3 | S2 S5 | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 15:26 |
| S8 | 3 | S7 and (hydrophobic hydrophilic) | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 15:26 |

| | | | | | | |
|-----|------|--|------------------------|----|----|------------------|
| S9 | 1006 | ((hydrophobic and hydrophilic) same (substrate wafer semiconductor workpiece)) and ((rins \$3 wash\$3 clean\$3) same (water near3 (pure\$2 purif\$3 purification demin demineraliz\$5))) | US-PGPUB; USPAT | OR | ON | 2010/05/07 15:34 |
| S10 | 728 | S9 and water same film | US-PGPUB; USPAT | OR | ON | 2010/05/07 15:36 |
| S11 | 564 | S10 and water same (reduc\$3 less lessen\$3 small\$2) | US-PGPUB; USPAT | OR | ON | 2010/05/07 15:37 |
| S12 | 141 | S11 and water same (reduc\$3 less lessen\$3 small\$2) same (mov\$3 rotat\$3) | US-PGPUB; USPAT | OR | ON | 2010/05/07 15:38 |
| S13 | 114 | S12 and water same (suppl\$4 feed\$3 using use\$1) same (reduc\$3 less lessen\$3 small\$2) same (mov\$3 rotat\$3) | US-PGPUB; USPAT | OR | ON | 2010/05/07 15:39 |
| S14 | 29 | S13 and water same (suppl\$4 feed\$3 using use\$1) same (reduc\$3 less lessen\$3 small\$2) same (mov\$3 rotat\$3) same film | US-PGPUB; USPAT | OR | ON | 2010/05/07 15:39 |
| S15 | 1 | "20030084925".pn. | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 17:39 |
| S16 | 1 | S15 and (hydrophobic hydrophilic) | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 17:39 |
| S17 | 1006 | ((hydrophobic and hydrophilic) same (substrate wafer semiconductor workpiece)) and ((rins \$3 wash\$3 clean\$3) same (water near3 (pure\$2 purif\$3 purification demin demineraliz\$5))) | US-PGPUB; USPAT | OR | ON | 2010/05/07 17:41 |
| S18 | 182 | S17 and (surface area) same ("both") same (hydrophobic and hydrophilic) | US-PGPUB; USPAT | OR | ON | 2010/05/07 17:41 |

| | | | | | | |
|-----|-----|--|------------------------|----|----|------------------|
| S19 | 21 | S18 and (surface area) near5 ("both") near5 (hydrophobic and hydrophilic) | US-PGPUB; USPAT | OR | ON | 2010/05/07 17:42 |
| S20 | 6 | ("5882433" "6221168" "6398975" "6406551" "6491764").PN. OR ("7011715").URPN. | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 17:48 |
| S21 | 4 | S20 and (hydrophobic and hydrophilic) | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 17:48 |
| S22 | 189 | S17 and (surface area region) same ("both") same (hydrophobic and hydrophilic) | US-PGPUB; USPAT | OR | ON | 2010/05/07 17:50 |
| S23 | 397 | ((substrate wafer semiconductor workpiece) near5 (rins \$3 wash\$3 clean\$3)) and ((surface area region) near5 ("both" mixed) near5 (hydrophobic and hydrophilic)) | US-PGPUB; USPAT | OR | ON | 2010/05/07 17:52 |
| S24 | 90 | S23 and ((substrate wafer semiconductor workpiece) near5 (rins \$3 wash\$3 clean\$3) near5 water) | US-PGPUB; USPAT | OR | ON | 2010/05/07 17:53 |
| S25 | 1 | "6058945".pn. | US-PGPUB; USPAT; USOCR | OR | ON | 2010/05/07 22:51 |

5/ 8/ 2010 1:26:22 AM

C:\ Documents and Settings\ egolightly\ My Documents\ EAST\ Workspaces\ App 10577314b.wsp